

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	27	((polishing and etching) and trench adj insulation).clm.	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/20 09:42
L2	0	((polishing and etching) and trench adj insulation and overfill).clm.	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/20 09:43
L3	0	((polishing and etching) and trench adj insulation and outermost).clm.	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/20 09:43
L4	22	((polishing and etching) and trench adj insulation and substrate).clm.	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/20 09:43